TOUCHSCREEN SERIES C FOR 8" (200mm) WAFERS

AUTOMEGASAMDRI®-938



- The New Supercritical Automegasamdri®-938 System was developed by our in-house design team whose goal was to listen to and incorporate your needs into our next generation.
- The classic features you have come to expect for decades that enable smooth operation, precise control and reproducibility are again evident in our most current design!



Automegasamdri®-938

Catalog# 8788C (Process Various Wafer Sizes up to 8in - 200mm)

- Process up to Five 8" (200mm) Wafers per Process Run
- Touchscreen Programmable Interface
- First Time Ever...Previous Run Data Review
- Integrated Chiller Loop Decreases LCO2 Consumption
- Easy Facilitation with Small Foot Print Design

FEATURES

- A dedicated initial Slow Fill into the process chamber allows ideal fluid dynamics preserving the most sensitive micro devices.
- Maintenance made easy via accessible components including the external Post-Purge-Filter assembly.
- Patent Pending "Vortex Swirl": Non-mechanical stirring chamber allowing for fluid dynamic exchange without the need for particle generating friction causing devices.*
- Extremely Efficient integrated Closed Cooling Loop dropping chamber temperature quickly for shorter process run times.*
- The internal SOTER(tm) condenser* quietly captures and separates CO₂ exhaust and waste alcohols.
- Our original Chamber Inserts enable chamber I.D. variance of chamber I.D. maximizing efficiency in LCO₂ consumption, process time, and providing multiple size wafer process capability!
- Process chamber LCO₂ filtration down to 0.08µm with 99.999%+ particle retention.
- Processes up to five 8" (200mm) wafers each run. Included are the following HF Compatible Wafer Holders: 8" (200mm), 6" (150mm), 4" (100mm), 3" (75mm), 2" (50mm) and 10mm Die Holders.
- Chamber Illumination via viewing window facilitates chamber status visualization.*
- Automatic process with factory default recipe or the ability to customize your own!*
- All internal surfaces are inert to CO₂ and ultrapure alcohols.
- Repeatable operating parameters insuring "reproducibility" of results.
- Safety operation features integrated into both temperature and pressure automatic regulation.
- All electronic components meet CE, UL and/or U.S. Military Specifications.
- Clean room static-free compatible design.

Double T-Filter Assembly LCO₂ Tank Connector LCO₂ Inlet HighPressure Hose

Samdried™ Wafer

Airdried Wafer

Standard Accessories

SPECIFICATIONS

- Cabinet: 19.8" (50.3cm) Width x 31.7" (80.6cm) Depth x 44.5" (113.0cm) Height
- System Set-Up Area Footprint: 27" (68.6cm) Width x 38" (96.5cm) Depth
- Chamber size: 8.50" I.D. x 1.25" Depth / Chamber volume: 1162 ml
- 120V or 220V / 50-60Hz
- LCO2 flow is precisely controlled through Micro Metering Valves with Vernier handles for adjustment ease.*

STANDARD ACCESSORIES

- High Pressure LCO₂ flexi-SS316 Braided line for safe operation and easy installation 10ft/3m length included with system. (Other lengths available upon request up to 100 ft/30m)
- Double T-Filter Assembly (#8785) pre-installed onto the chamber LCO2 supply high-pressure hose.
- Static free exhaust tubing included for all exhaust ports.
- Spare chamber O-rings (3), chamber lamp (1), and slo-blow fuses (2x3A and 2x8A).
- Chamber Inserts included: 8" to 6"/ 6" to 4" / 4" to 3" / 3" to 2" / 2" to 1.25"! Allows for multiple wafer size drying.
- HF compatible wafer holders included: 8" (200mm), 6" (150mm), 4" (100mm), 3" (75mm), 2" (50mm) and 10mm square die. Each holder can load up to five substrates each.
- 2 year warranty on all parts and labor.
- Free lifetime technical support.

